GAS | Products For Gas Applications

MASS FLOW CONTROLLER

Low Differential Pressure Mass Flow Controller MC-3000S Series



Outlines

 MC-3000S Series: Mass flow controller equipped with LINTEC's original low pressure differential device to operate at low differential pressure environment

Features

- Low pressure differential device
- In addition to AsH₃ and PH₃ for ion implantation, this MFC is also applicable to solid state material and liquified gas without heating
- RS-485 digital interface
- LINTEC's unique ambient temperature-compensated sensor incorporated
- Highly functional upon installation of microprocessor
- Diaphragm valve with small dead volume
- High-speed and high performance piezoelectric actuator
- Long-term leak tightness ensured using metal seal
- By using metal case and various filters, stable operation can be achieved through reduction of radio frequency noises and electromagnetic field interferences

C€ RoHS

Model	MC-3102S		
Flow rate in Nitrogen (Full scale)	2~10SCCM	~ 20SCCM	~ 30SCCM
Flow rate control range	2~100% F.S.		
Valve operation mode	Normally open, Normally closed		
Accuracy	±1.0% F.S.		
Repeatability	±0.2% F.S.		
Response time	2 sec		
Analog flow rate setting signa	0 ~ 5VDC		
Analog flow rate output signa	0~5VDC		
Operating differential pressur	e 8×10 ² Pa ~ 1.33×10 ⁵ Pa	1.07×10³Pa ∼ 1.33×10⁵Pa	1.33×10³Pa ∼ 1.33×10⁵Pa
Withstand pressure	1MPa(G)		
Temperature Zero	±0.02% F.S. / °C		
coefficient Span	±0.02% F.S. / °C	±0.04% F.S. / °C	±0.08% F.S. / °C
Operating temperature	5~50°C 0~80% RH		
Leak integrity	1×10 ⁻¹¹ Pa·m ³ / sec He		
Materials exposed to gas	SUS316L, SUS304, PCTFE		
Seal materials	Au		
Power supply requirement	+15VDC±3% 100mA, -15VDC±3% 50mA		
Mounting position	Specified upon order placement		
Analog connector	Dsub 9pin		
Digital interface	RJ45/RS-485		
Control valve actuator	Piezoelectric actuator		
Weight	1.0kg		



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